

# **Device Modeling Report**

COMPONENTS: Power MOSFET (Professional)  
PART NUMBER: 2SK3561  
MANUFACTURER: TOSHIBA  
Body Diode (Professional) / ESD Protection Diode



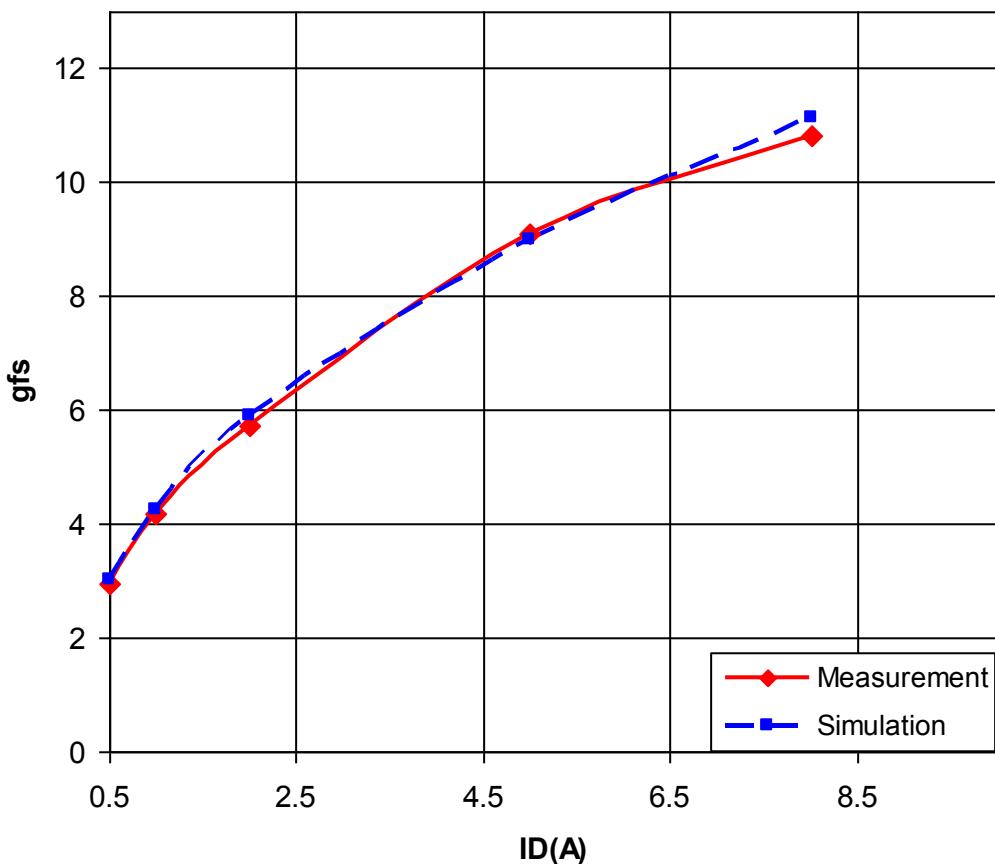
**Bee Technologies Inc.**

## MOSFET MODEL

PSpice model parameter	Model description
LEVEL	
L	Channel Length
W	Channel Width
KP	Transconductance
RS	Source Ohmic Resistance
RD	Ohmic Drain Resistance
VTO	Zero-bias Threshold Voltage
RDS	Drain-Source Shunt Resistance
TOX	Gate Oxide Thickness
CGSO	Zero-bias Gate-Source Capacitance
CGDO	Zero-bias Gate-Drain Capacitance
CBD	Zero-bias Bulk-Drain Junction Capacitance
MJ	Bulk Junction Grading Coefficient
PB	Bulk Junction Potential
FC	Bulk Junction Forward-bias Capacitance Coefficient
RG	Gate Ohmic Resistance
IS	Bulk Junction Saturation Current
N	Bulk Junction Emission Coefficient
RB	Bulk Series Resistance
PHI	Surface Inversion Potential
GAMMA	Body-effect Parameter
DELTA	Width effect on Threshold Voltage
ETA	Static Feedback on Threshold Voltage
THETA	Mobility Modulation
KAPPA	Saturation Field Factor
VMAX	Maximum Drift Velocity of Carriers
XJ	Metallurgical Junction Depth
UO	Surface Mobility

## Transconductance Characteristic

Circuit Simulation Result

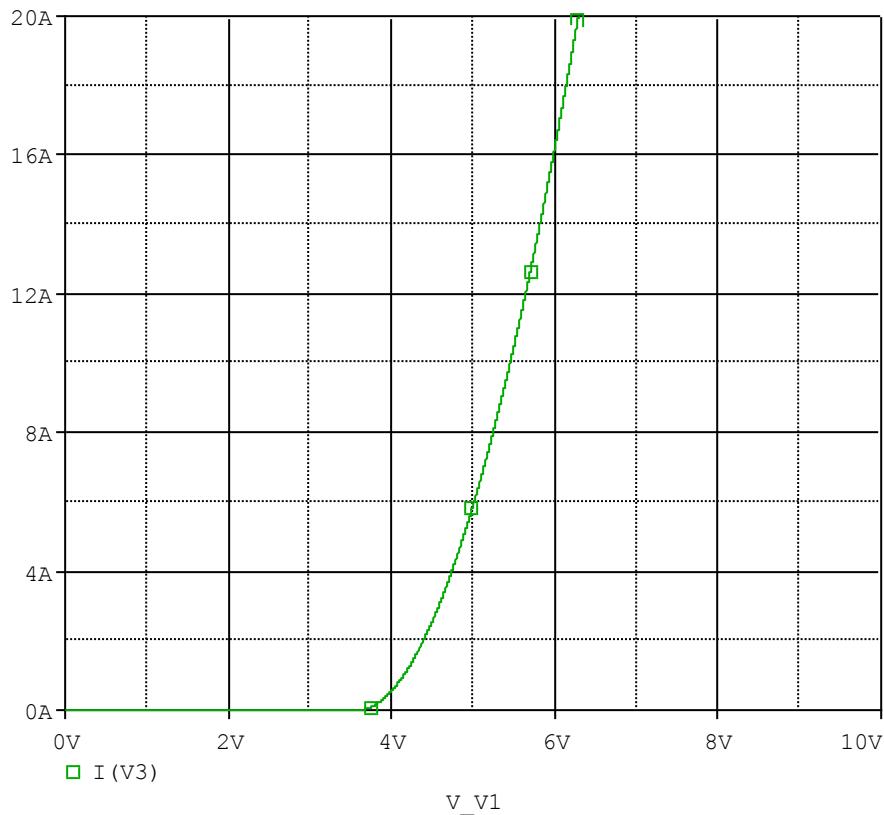


Comparison table

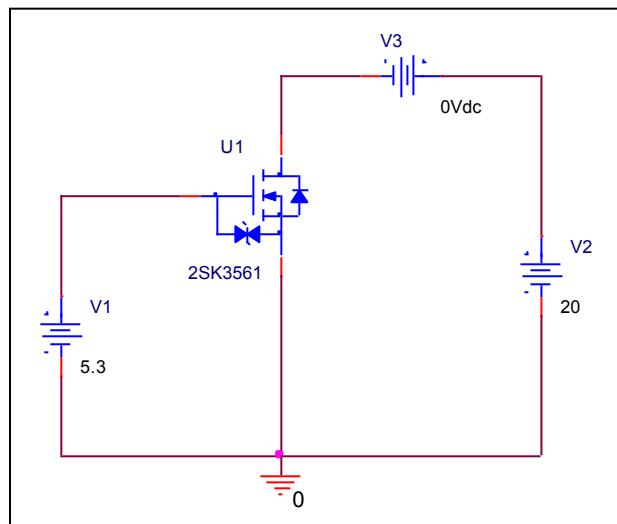
Id(A)	gfs		Error(%)
	Measurement	Simulation	
0.5	2.941	3.030	3.026
1	4.167	4.255	2.112
2	5.714	5.900	3.255
5	9.091	9.009	-0.902
8	10.811	11.127	2.923

## V<sub>gs</sub>-I<sub>d</sub> Characteristic

Circuit Simulation result

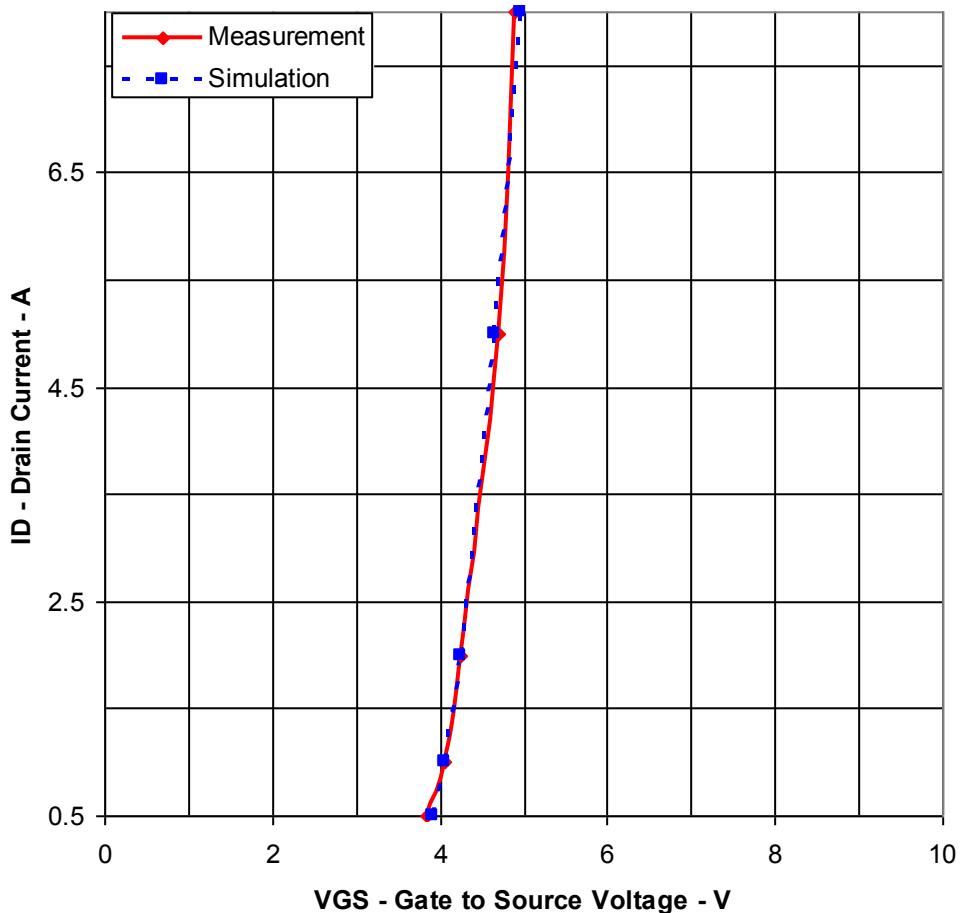


Evaluation circuit



## Comparison Graph

Circuit Simulation Result

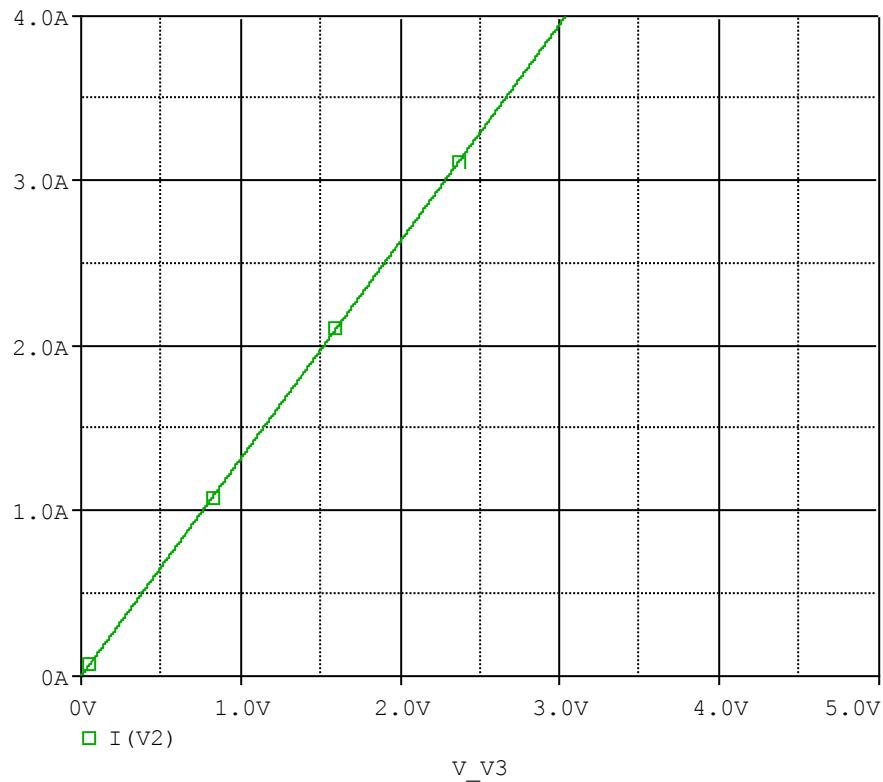


Simulation Result

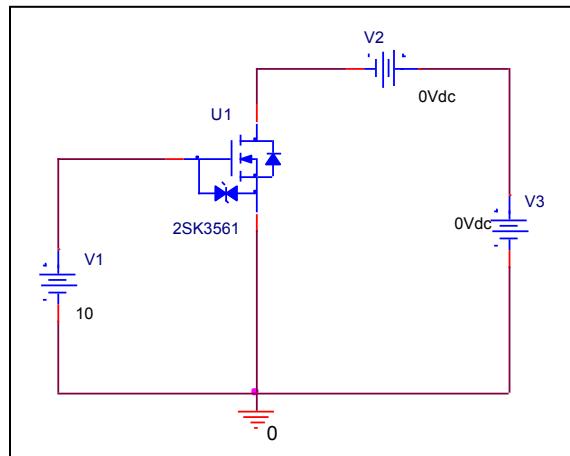
$I_D$ (A)	$V_{GS}$ (V)		Error (%)
	Measurement	Simulation	
0.5	3.85	3.9070	1.481
1	4.05	4.0475	-0.062
2	4.25	4.249	-0.024
5	4.7	4.659	-0.872
8	4.9	4.9629	1.284

## Rds(on) Characteristic

Circuit Simulation result



Evaluation circuit

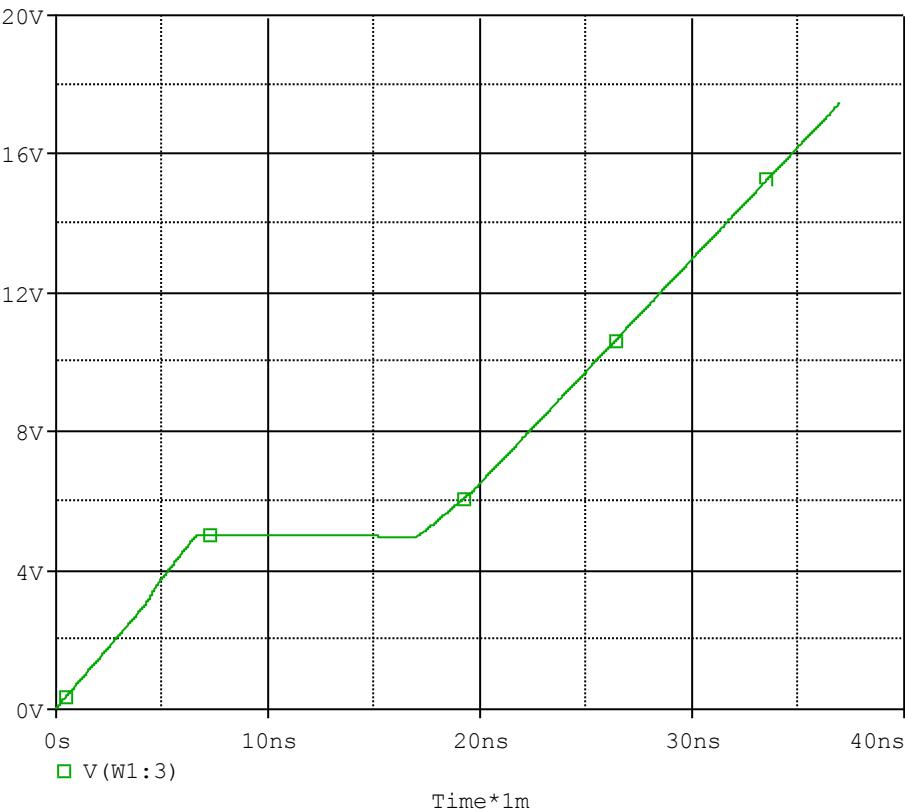


Simulation Result

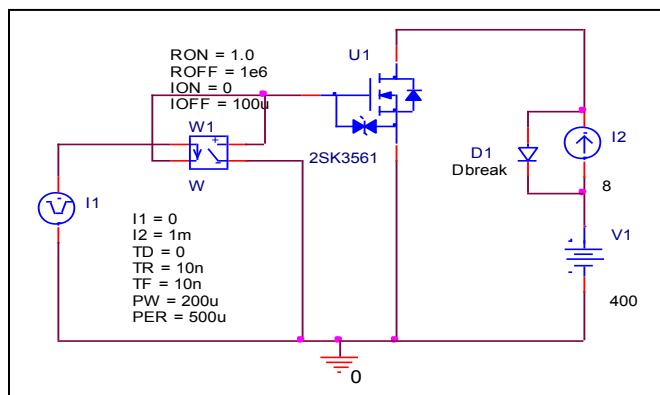
I <sub>D</sub> =4A, V <sub>GS</sub> =10V	Measurement		Simulation		Error (%)
R <sub>DS</sub> (on)	0.75	Ω	0.759	Ω	1.2

## Gate Charge Characteristic

### Circuit Simulation result



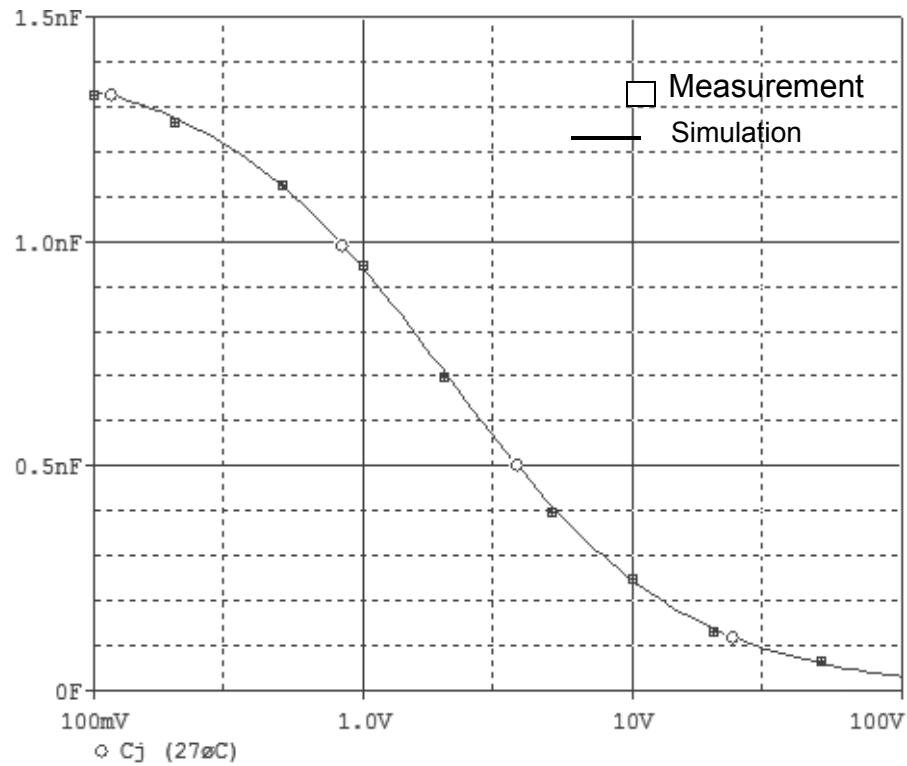
### Evaluation circuit



### Simulation Result

$V_{DD}=400V, I_D=8A$	Measurement		Simulation		Error (%)
Qgs	6.5	nC	6.6038	nC	1.597
Qgd	10	nC	10.377	nC	3.770
Qg	26.5	nC	25.409	nC	-4.117

## Capacitance Characteristic

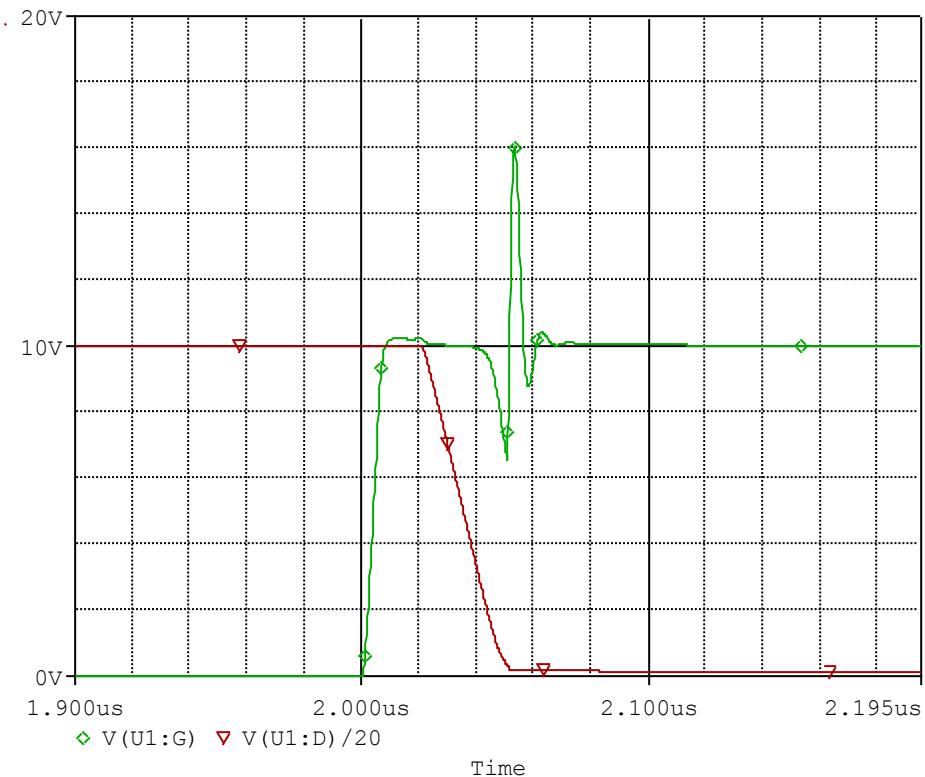


### Simulation Result

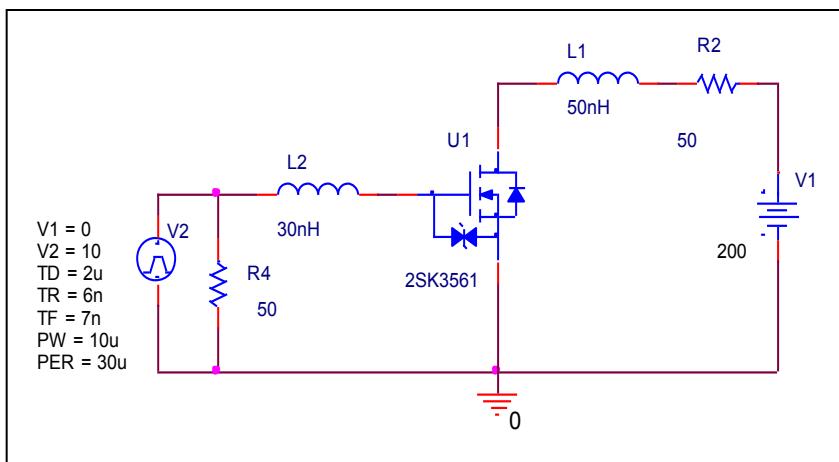
$V_{ds}$ (V)	C <sub>bd</sub> (pF)		Error(%)
	Measurement	Simulation	
0.1	1330	1335	0.376
0.2	1270	1275	0.394
0.5	1130	1120	-0.885
1	950	940	-1.053
2	700	710	1.429
5	400	410	2.500
10	255	245	-3.922
20	134	137	2.239

## Switching Time Characteristic

Circuit Simulation result



Evaluation circuit

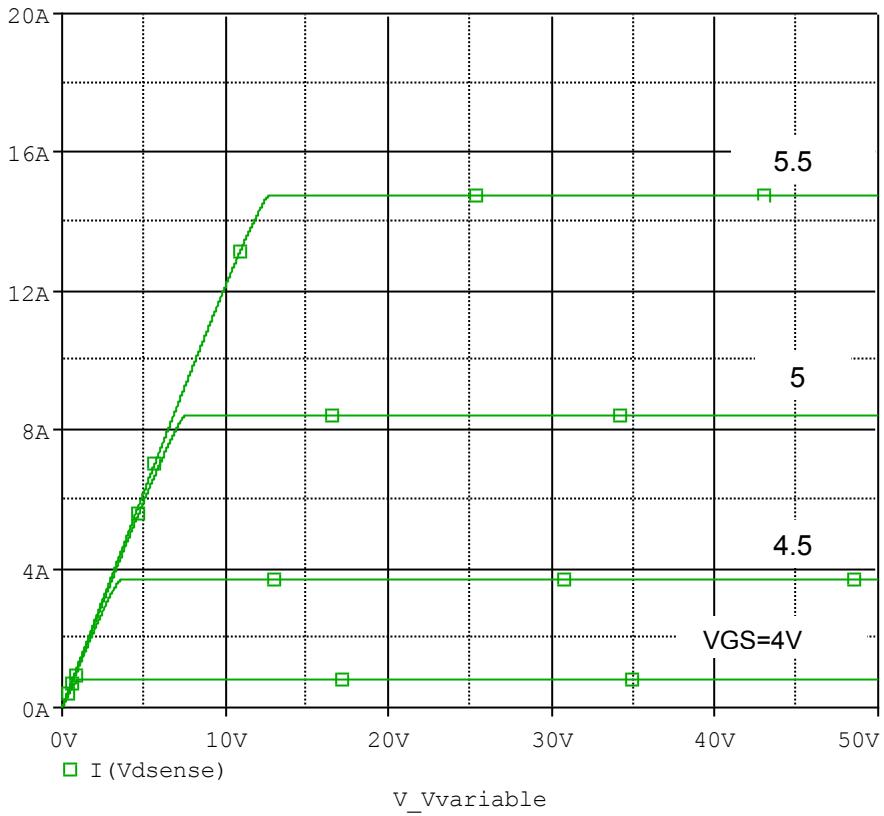


Simulation Result

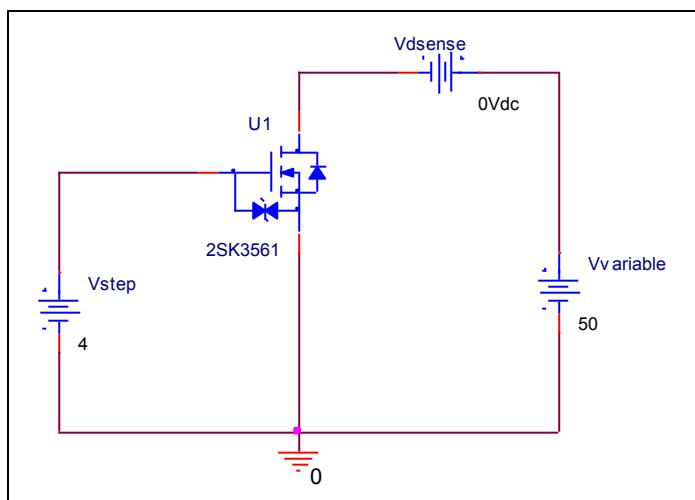
$I_D=4 A$ , $V_{DD}=200V$ $V_{GS}=0/10V$	Measurement	Simulation	Error(%)
<b>ton</b>	<b>45.000</b> ns	<b>45.513</b> ns	<b>1.140</b>

# Output Characteristic

## Circuit Simulation result

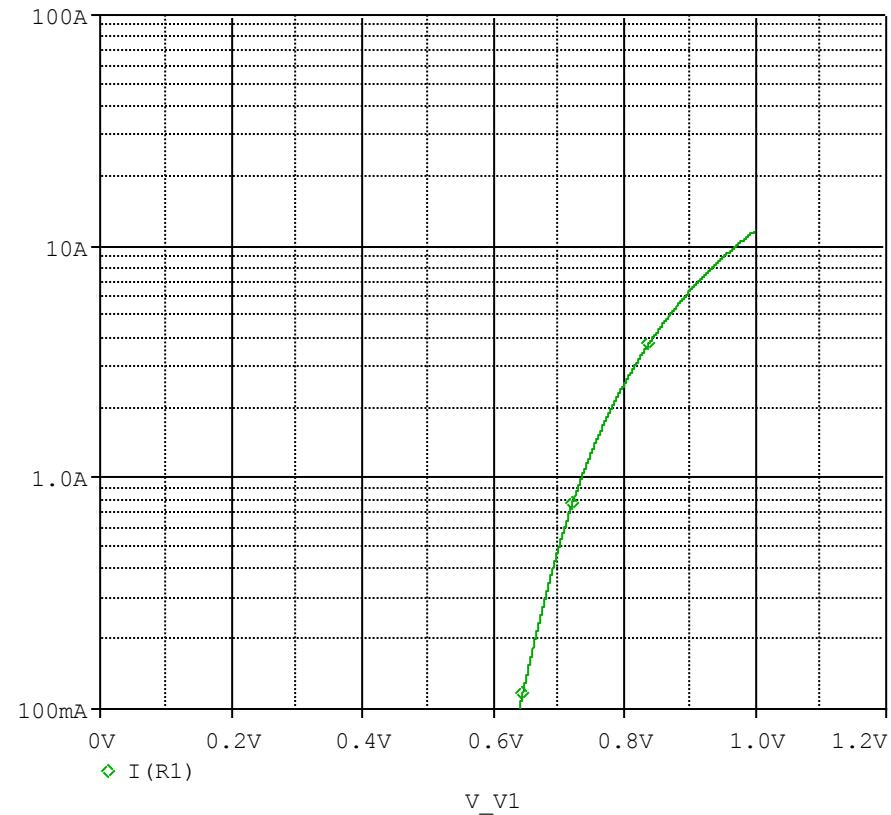


## Evaluation circuit

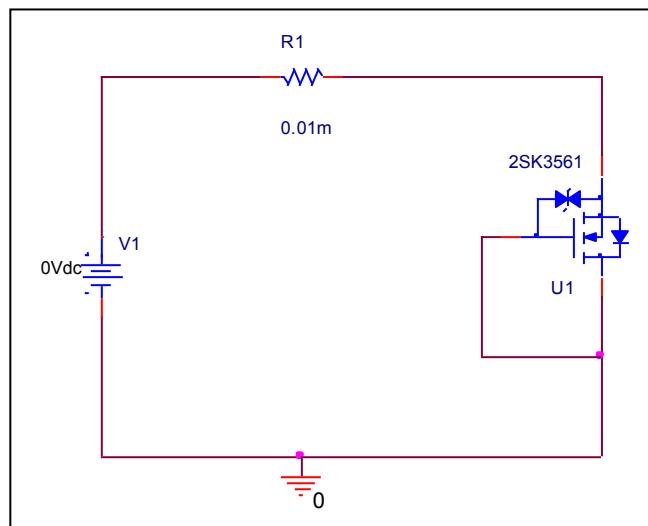


## Forward Current Characteristic

### Circuit Simulation Result

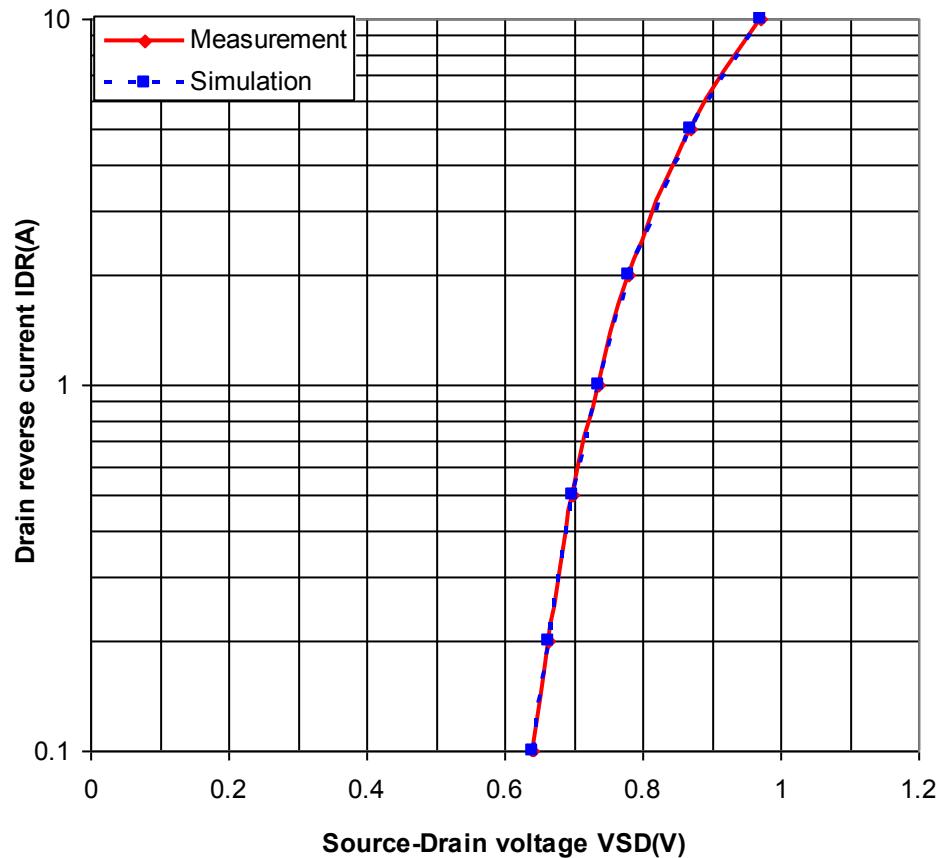


### Evaluation Circuit



## Comparison Graph

Circuit Simulation Result

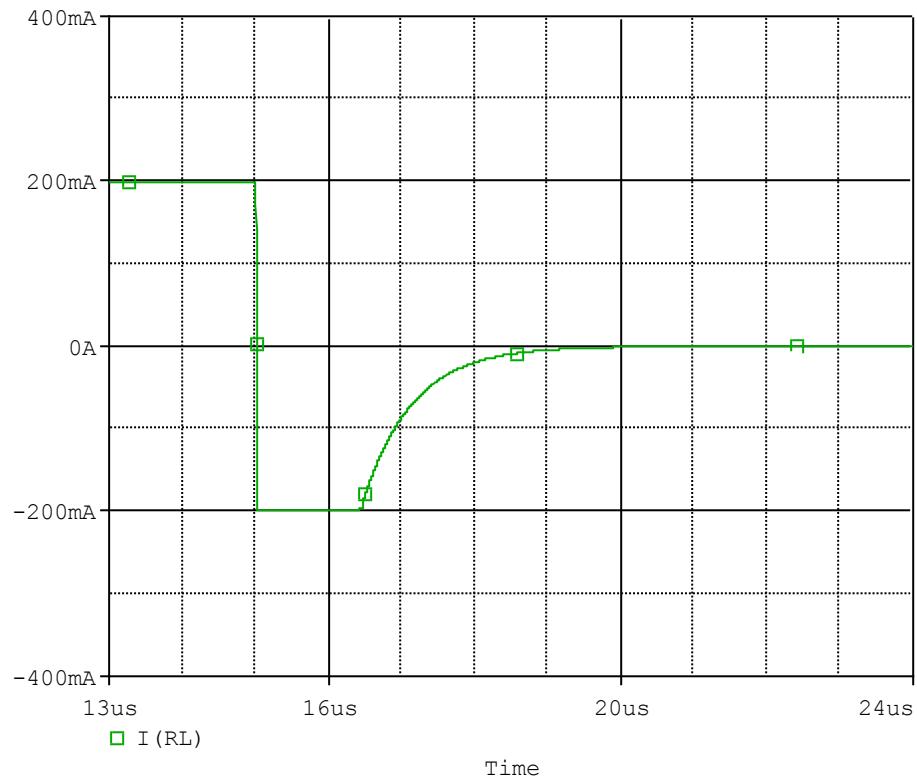


Simulation Result

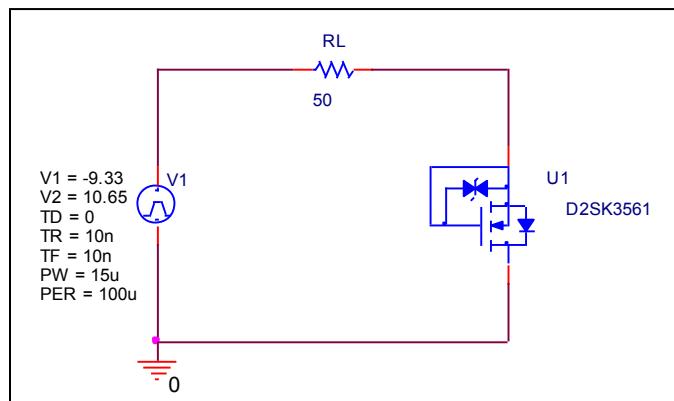
Ifwd(A)	VSD(V)		%Error
	Measuremen	Simulation	
0.1	0.64	0.64	0
0.2	0.665	0.664	-0.150
0.5	0.7	0.7	0
1	0.735	0.735	0
2	0.78	0.781	0.128
5	0.87	0.869	-0.115
10	0.97	0.971	0.103

## Reverse Recovery Characteristic

Circuit Simulation Result



Evaluation Circuit

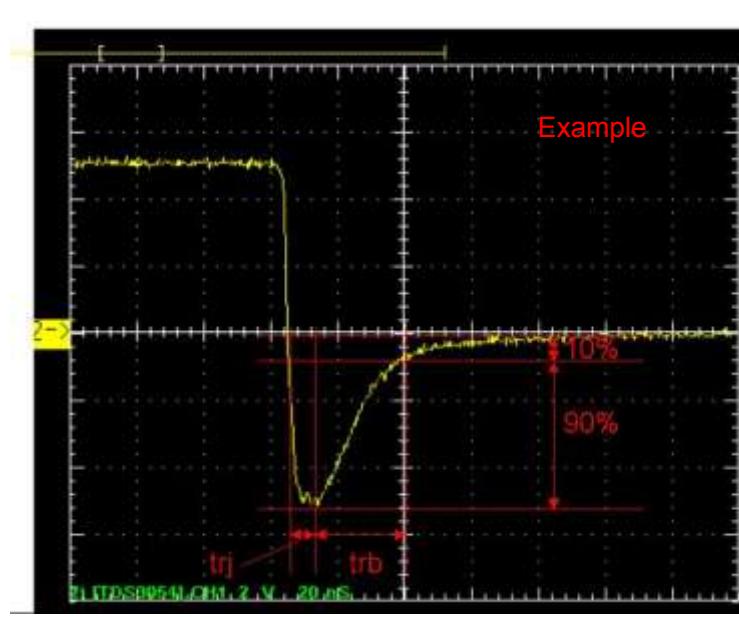
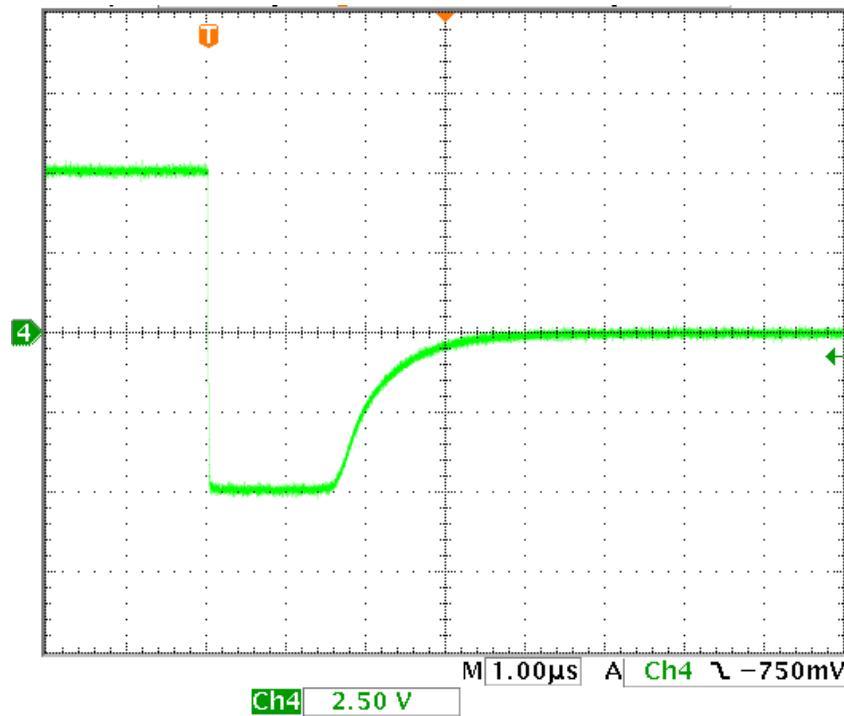


Compare Measurement vs. Simulation

	Measurement	Simulation	Error (%)
$Trj(\mu s)$	<b>1.44</b>	<b>1.4402</b>	<b>0.014</b>
$Trb(\mu s)$	<b>1.52</b>	<b>1.5374</b>	<b>1.145</b>
$Trr(\mu s)$	<b>2.96</b>	<b>2.9776</b>	<b>0.595</b>

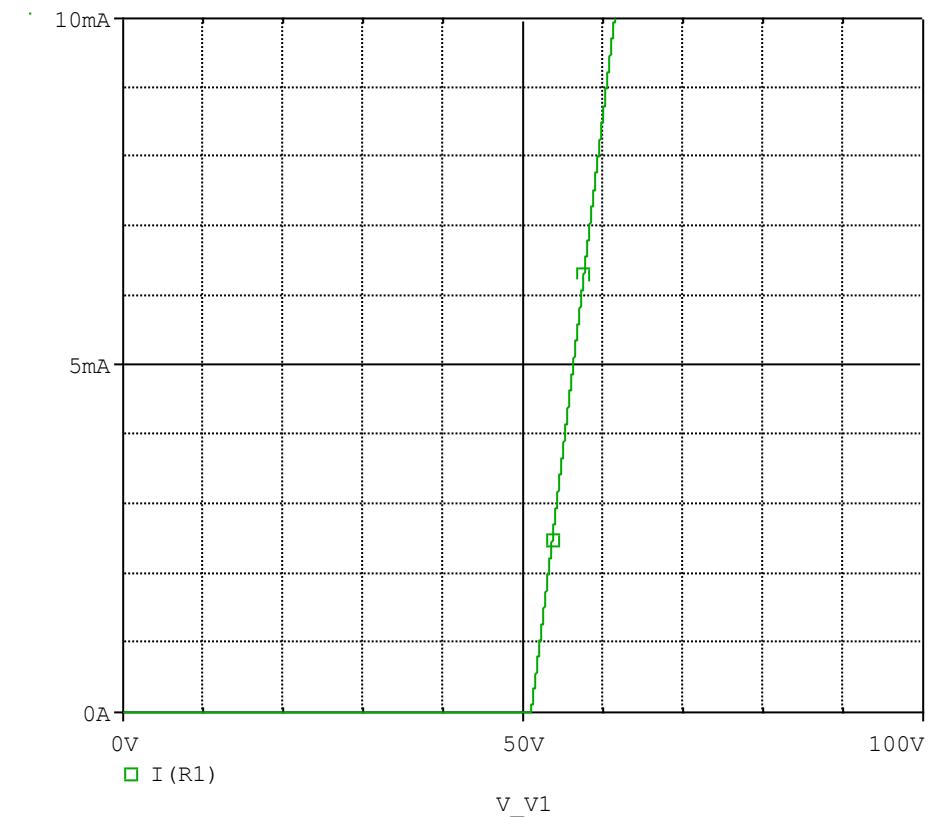
## Reverse Recovery Characteristic

Reference

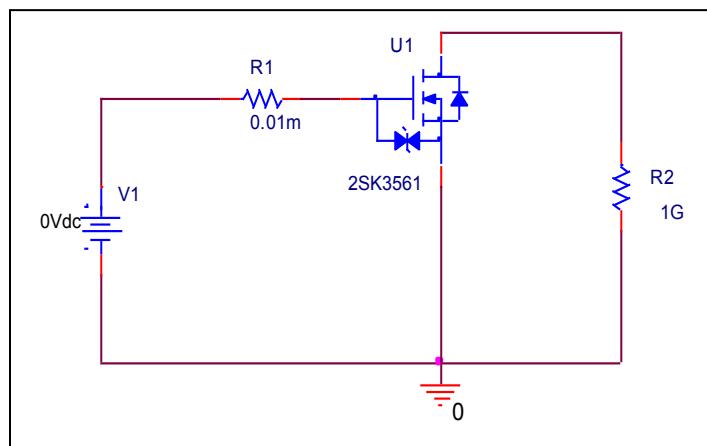


## ESD PROTECTION DIODE Zener Voltage Characteristic

### Circuit Simulation Result



### Evaluation Circuit



## Zener Voltage Characteristic

## Reference

